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WHAT IS CLAIMED IS:

1. A system for processing flat media, comprising:

an indexer at a first elevation;

a docking station at a second elevation higher than the first elevation;

a transfer station adjacent to the docking station;

a process station;

and a robot movable between the transfer station and the process station, for

moving flat media between them.

- 2. The system of claim 1 further including a loader associated with the indexer, the loader having a load elevator for moving a closed pod of flat media between an up position, and a down position, and with the load elevator in the down position substantially aligned with the indexer at the first elevation.
- 3. The system of claim 2 with the loader having a loader conveyor for moving a pod from the loader onto the indexer.
- 4. The system of claim 1 with the indexer comprising at least one drive section having a plurality of rollers for supporting a pod, and with a drive motor linked to at least one of the rollers.

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- 5. The system of claim 4 where the rollers support the pod only at the outside lateral edges of the pod.
- 6. The system of claim 1 where the indexer comprises a first row and second row parallel to the first row, and at least one shuttle device for moving a pod from the first row to the second row.
- 7. The system of claim 6 where the shuttle device moves a pod in a direction perpendicular to the direction that the rollers move the pod.
- 8. The system of claim 1 further including at least one docking station elevator for moving a pod vertically from the first elevation to the docking station at the second elevation.
- 9. The system of claim 1 further comprising a pod door remover at the docking station.

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- 10. The system of claim 2 with the loader further comprising a pod rotator.
- 20 11. A method for processing at least one wafer contained within a closed pod, comprising the steps of:

removing the at least one wafer from the pod;

transferring the at least one wafer into a carrier, while maintaining the at least one wafer in a substantially horizontal orientation;

engaging the carrier with a robot arm;

pivoting the carrier so that the at least one wafer is moved into a non-5 horizontal orientation, so that the at least one wafer is held within the carrier at least in part by gravity;

moving the robot with the carrier to a processor;

placing the carrier with the at least one wafer into the processor.

12. A method for processing wafers provided within a closed pod, comprising the steps of:

placing the pod onto a loader;

lowering the pod from a first elevation to a second elevation;

moving the pod from the loader to an indexer at the second elevation; and moving the pod to a docking station by lifting the pod from the second elevation to a third elevation above the first and second elevations.

- 13. The method of claim 12 further including the step of rotating the pod 180 degrees on a pod rotator in the loader.
- 14. The method of claim 12 where the indexer has a first row and a second row, and further including the step of shuttling the pod from the first row to the second row.

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